

NNT 2011 Program

Oct. 19 (Wed), 2011	
9:00~10:30	Registration
10:30~11:00	Opening Ceremony
11:00~11:25	Technical Session: Metrology, Standards and Reliability IT: Ryuta Washiya (Hitachi)
11:25~11:40	OT: Kenta Suzuki (AIST)
11:40~11:55	OT: Daesuk Kim (Chonbuk National Univ.)
11:55~12:10	OT: Akira Horiba (Osaka. Prefecture Univ.)
12:10~13:30	Lunch
13:30~14:00	Plenary Speech: Stephen Chou (Princeton Univ.)
14:00~14:30	Plenary Speech: Jong Min Kim (Samsung Electronics)
14:30~14:55	Technical Session: Material Issues IT: L. Jay Guo (Univ. of Michigan)
14:55~15:20	IT: Se-Jin Choi (Minuta Technology)
15:20~15:35	OT: Iris Bergmair (PROFACTOR GmbH)
15:35~15:50	OT: Khalid Dhima (Univ. of Wuppertal)
15:50~16:05	OT: Ayoung Lee (Seoul National Univ.)
16:05~16:20	OT: Naoki Nishikura (Osaka Prefecture Univ.)
16:20~16:50	Coffee Break / Poster Presentation
16:50~17:15	Technical Session: Stamp, Templates and Equipment IT: Doug Resnick (Molecular Imprints)
17:15~17:30	OT: Makoto Okada (Univ. of Hyogo)
17:30~17:45	OT: Andre Mayer (Univ. of Wuppertal)
17:45~18:00	OT: Atsushi Yokoo (NTT Basic Research Laboratories)
18:00~18:15	OT: Si-Hyeong Cho (Hanyang Univ.)
18:30~19:30	Welcome Reception

Oct. 20 (Thu), 2011	
8:00-8:30	Registration
8:30-8:55	Technical Session: Process and Modeling IT: Helmut Schiff (Paul Scherrer Institut Villigen)
8:55-9:10	OT: Hiroshi HIROSHIMA (AIST)
9:10-9:25	OT: Kentaro ISHIBASHI (WASEDA University / Toshiba machine)
9:25-9:40	OT: Po Jin KIM (Pusan National Univ.)
9:40-9:55	OT: Jian HE Ge (SiM-Gesellschaft fuer Silizium-Mikrosysteme mbH)
9:55-10:15	Coffee Break / Poster Presentation
10:15-10:45	Plenary Speech: Shuichi Shoji (Waseda Univ.)

10:45-11:10	IT: Jouni Ahopeito (VTT Microsystems and Nanoelectronics)
11:10-11:25	OT: Sanghyeok KIM (KAIST)
11:25-11:40	OT: Jong-Ning AOH (National Chung Cheng Univ.)
11:40-11:55	OT: Hayden TAYLOR (Simprint Nanotechnologies)
11:55-12:10	OT: Thomas BU (Institut for Mikro-og Nanoteknologi)
12:10-13:30	Lunch
13:30-14:00	Plenary Speech: S.V.Sreenivasan (Molecular Imprints)
14:00-14:25	Technical Session: Application I : Electronics/Magnetics, Optoelectronics/ Optics and Photovoltaics IT: Yoshihiro Uozu (Mitsubishi Rayon)
14:25-14:40	OT: Henry J. H. CHEN (National Chi Nan Univ.)
14:40-14:55	OT: Iris BERGMAYER (PROFACTOR GmbH)
14:55-15:10	OT: Shinill KANG (Yonsei Univ.)
15:10-15:35	IT: Marc Verschuuren (Philips Corporate Technologies)
15:35-15:50	OT: Joonam KIM (TIT)
15:50-16:05	OT: Youngtae CHO (Samsung Electronics)
16:05-16:20	OT: Vaida AUZELYTE (EPFL)
16:20-18:20	Poster Presentation
18:30-21:00	Banquet

Oct. 21 (Fri), 2011	
8:00-8:30	Registration
8:30-8:55	Technical Session: Application II: Biology/u-TAS, Biomimetics, Self-assembly, Chemistry IT: Dongpyo Kim (Chungnam Univ.)
8:55-9:20	IT: Yong Chen (CNRS)
9:20~9:45	IT: Deok-Ho Kim (Univ. of Washington)
9:45-10:00	OT: Keiko TAWA (AIST)
10:00-10:15	OT: Hong Yee LOW (Institute of Materials Research and Engineering)
10:15-10:30	OT: Sun CHOI (UC Berkeley)
10:30-10:45	OT: Jihye Lee (KIMM)
10:45-11:10	Coffee Break
11:10-11:35	Technical Session: Roll to Roll IT: Ohseung Kwon (Phicot, Inc. / HP Labs)
11:35-11:50	OT: Erwin MEINDERS (TNO)
11:50-12:05	OT: Hiroyuki SUYAMA (PULSTEC INDUSTRIAL)
12:05-13:30	Lunch
13:30-13:55	IT: Akihiko Hagiwara (Toshiba Machine)
13:55-14:10	OT: Jarrett DUMOND (IMRE)
14:10-14:25	OT: Yung-Chun Lee (National Cheng Kung Univ.)
14:25-14:40	OT: Masayuki ABE (Asahi Kasei Engineering)